

| Ref # | Hits | Search Query | DBs | Default Operator | Plurals | Time Stamp |
|-------|------|---|----------------------------------|------------------|---------|------------------|
| L1 | 75 | 438/31.ccls. 438/481.ccls. 438/494.ccls. 438/507.ccls. 438/695.ccls. 117/58.ccls. 117/95. ccls. 117/104.ccls. | USOCR | OR | OFF | 2006/01/20 08:21 |
| L2 | 2140 | 438/31.ccls. 438/481.ccls. 438/494.ccls. 438/507.ccls. 438/695.ccls. 117/58.ccls. 117/95. ccls. 117/104.ccls. | US-PGPUB; USPAT | OR | OFF | 2006/01/20 08:23 |
| L3 | 9817 | sage (selective adj area adj (grow\$6 etch\$6)) | US-PGPUB; USPAT | OR | ON | 2006/01/20 08:23 |
| L4 | 73 | L2 and L3 | US-PGPUB; USPAT | OR | ON | 2006/01/20 08:23 |
| L5 | 457 | L3 same (mask\$6 epitax\$6 cvd (chemical adj vapor)) | US-PGPUB; USPAT | OR | ON | 2006/01/20 08:59 |
| L6 | 411 | L5 and (wafer substrate) | US-PGPUB; USPAT | OR | ON | 2006/01/20 08:31 |
| L7 | 4930 | sage (selective adj area adj (grow\$6 etch\$6)) | EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/01/20 08:44 |
| L8 | 82 | L7 and (mask\$6 epitax\$6 cvd (chemical adj vapor)) | EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/01/20 08:44 |
| L9 | 144 | L7 and (wafer substrate) | EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/01/20 08:47 |
| L10 | 17 | ("3574008").URPN. | USPAT | OR | OFF | 2006/01/20 08:49 |
| L11 | 6 | ("3458369").URPN. | USPAT | OR | OFF | 2006/01/20 08:50 |
| L12 | 17 | ("3400309").URPN. | USPAT | OR | OFF | 2006/01/20 08:50 |
| L13 | 10 | ("3579055").URPN. | USPAT | OR | OFF | 2006/01/20 08:51 |
| L14 | 20 | ("4466173").URPN. | USPAT | OR | OFF | 2006/01/20 08:51 |
| L15 | 8 | ("4466173" "4758531" "5216275" "5438215" "5463254" "5739563" "5893735").PN. OR ("6495294"). URPN. | US-PGPUB; USPAT; USOCR | OR | OFF | 2006/01/20 08:53 |
| L17 | 323 | 438/481.ccls. | US-PGPUB; USPAT | OR | OFF | 2006/01/20 08:54 |
| L18 | 30 | ((sage (selective adj area adj (grow\$6 etch\$6))) and (mask\$6 epitax\$6 cvd (chemical adj vapor))).clm. | US-PGPUB | OR | ON | 2006/01/20 09:01 |